

FORM PTO-1449
(Modified)U.S. DEPARTMENT OF COMMERCE
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06336P USA

SERIAL NO.

10/624,350

INFORMATION DISCLOSURE
STATEMENT BY APPLICANT
(Use several sheets if necessary)APPLICANT
Aaron Scott Lukas, et al.

(37 CFR 1.98(b))

FILING DATE

7/24/03

GROUP

1762

U.S. PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	5 4 5 4 9 1 5	10/3/1995	J. S. Shor, et al. ✓	204	129.3	9/1/1993
	6 0 4 2 9 9 4	3/28/2000	J. Yang, et al. ✓	430	296	1/8/1999
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	6 2 8 4 0 5 0	9/4/2001	J. Shi, et al. ✓	118	715	5/18/1998
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DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
EP 1 0 3 7 2 7 5	Sept-2000	Europe	Maeda et al.		YES NO
WO 0 0 0 2 2 4 1	Jan 2000	World	PCY		X
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A. Hozumi, et al., "Low-Temperature Elimination of Organic Components from Mesostructured Organic-Inorganic Composite Films Using Vacuum Ultraviolet Light, Chem. Mater. 2000, 12, 3842-3847. *no month*M. Ouyang, et al., "Conversion of Some Siloxane Polymers to Silicon Oxide by UV/Ozone Photochemical Processes, Chem Mater. 2000, 12, 1591-1596. *(no month, but published on Web May 2000)*

A. Hozumi, et al., "Micropatterned Silica Films with Ordered Nanopores Fabricated through Photocalcination, National Institute of Advanced Industrial Science & Technology, Volume 1, Number 8, August 2001.

T. Clark, Jr., et al., "A New Application of UV-Ozone Treatment in the Preparation of Substrate-Supported, Mesoporous Thin Films, Chem Mater. 2000, 12, 3879-3884. *no month, but pub on web - Dec. 2000*Q. Han, et al., "Ultra Low-k Porous Silicon Dioxide Films from a Plasma Process," IEEE (2001), pp. 171-173. *no month*C. Waldfried, et al., "Single Wafer RapidCuring™ of Porous Low-k Materials," IEEE (2002), pp. 226-228. *no month*

EXAMINER

Michael P. Gallet

DATE CONSIDERED

9/15/05

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Substitute for form 1449/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary) MAY 31 2005		Complete if Known	
		Application Number	10/624,356
		Filing Date	July 21, 2003
		First Named Inventor	Aaron Scott Lukas, et al.
		Art Unit	1762
		Examiner Name	M. L. Padgett
Sheet	1	Attorney Docket Number	06336P USA

U. S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. ¹	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			
MPP		US- 2005/0048795	03-03-2005	Ko, et al.	
		US-			
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FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ^o
		Country Code ³ Number ⁴ Kind Code ⁵ (if known)				
MPP		WO 2004/083495	09-30-2004	Gates, et al.		✓
		EP 1 482 550	12-01-2004	Ohdaira, et al.		✓
		WO 2005/019303	03-03-2005	Ree, et al.		✓
		TW 540118	03-28-1990	Zhengyuan, et al.		✓

Translation only
no original patent documents
provided

Examiner Signature	M. L. Padgett	Date Considered	9/15/05
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